

Title (en)

FLUX, AND METHOD FOR THE REDUCTION OF OXIDE LAYERS ON METALLIC SURFACES

Title (de)

FLUSSMITTEL UND VERFAHREN ZUR REDUZIERUNG VON OXIDSCHICHTEN AUF METALLISCHEN OBERFLÄCHEN

Title (fr)

FONDANT ET PROCÉDÉ POUR RÉDUIRE DES COUCHES D'OXYDE SUR DES SURFACES MÉTALLIQUES

Publication

EP 2049288 A2 20090422 (DE)

Application

EP 07725551 A 20070525

Priority

- EP 2007004655 W 20070525
- DE 102006035748 A 20060728

Abstract (en)

[origin: WO2008011933A2] The invention relates to a flux for application to and the reduction of oxide layers on a metallic solid or molten surface that is composed at least of potassium, fluoride, and moieties of water. The flux is formed from a reactant containing moieties of zirconium fluoride and/or lithium fluoride and/or sodium silicon fluoride and/or potassium cryolite and/or potassium aluminum fluoride (KAlF_4) as well as moieties of salts based on zirconium and/or lithium and/or potassium and/or sodium and/or bismuth and/or boron and/or titanium. The invention further relates to a method for casting basic aluminum alloys as well as the use of the disclosed flux for reducing oxide layers on molten basic aluminum alloys.

IPC 8 full level

B22D 19/00 (2006.01); **B22D 19/16** (2006.01); **B23K 35/36** (2006.01)

CPC (source: EP KR US)

B22D 19/0081 (2013.01 - EP KR US); **B22D 19/08** (2013.01 - EP KR US); **B22D 19/16** (2013.01 - EP KR US);
B23K 35/3605 (2013.01 - EP KR US); **B23K 35/362** (2013.01 - KR); **B23K 2103/02** (2018.07 - KR); **B23K 2103/10** (2018.07 - KR)

Citation (search report)

See references of WO 2008011933A2

Designated contracting state (EPC)

AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HU IE IS IT LI LT LU LV MC MT NL PL PT RO SE SI SK TR

Designated extension state (EPC)

AL BA HR MK RS

DOCDB simple family (publication)

WO 2008011933 A2 20080131; **WO 2008011933 A3 20080403**; BR PI0715432 A2 20130108; CN 101528389 A 20090909;
EP 2049288 A2 20090422; JP 2009544471 A 20091217; KR 20090042917 A 20090504; MX 2009000610 A 20090612;
US 2011146845 A1 20110623

DOCDB simple family (application)

EP 2007004655 W 20070525; BR PI0715432 A 20070525; CN 200780027678 A 20070525; EP 07725551 A 20070525;
JP 2009521118 A 20070525; KR 20097003188 A 20090217; MX 2009000610 A 20070525; US 37463707 A 20070525